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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)
Wu et al.) Group Art Unit: 2891
Serial No.: 10/672,778) Examiner: Smith, Bradley
Filed: September 26, 2003) Confirmation No.: 9717
For: Atomic Layer Deposition (ALD) Method with Enhanced Deposition Rate	TKHR Docket: 252016-3000 Top-Team: 0503-8501DUS
CERTIFICATE OF FACSIMILE TRANSMISSION UNDER 37 CFR §1.8 I hereby certify that this paper (along with any paper referred to as being attached or enclosed) is being transmitted on the date indicated below via facsimile to the United States Patent and Trademark Office, Technology Group 2100, facsimile number (571) 273-8300. Total number of pages in this transmission 9.	
February 14, 2005 Date Daniel R. McChure	

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Sir:

The Office Action mailed November 29, 2005 has been carefully considered. In further response thereto, please enter the following amendments and consider the following remarks.